## NOTES:

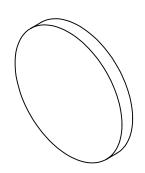
- 1. SUBSTRATE: UV FUSED SILICA
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- COATING (APPLY ACROSS COATING APERTURE) S1: HARD DIELECTRIC SPUTTERED T(avg): ≥91% FROM 1070 - 1650nm @ 0° AOI T(avg): ≤0.01% FROM 200 - 1030nm @ 0° AOI T(abs): =50% FOR 1050±10.5nm @ 0° AOI

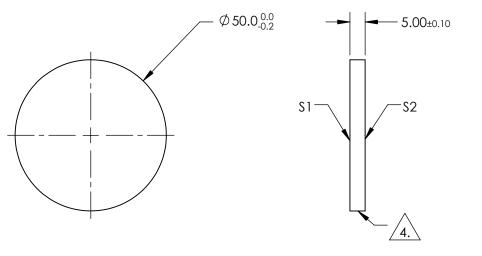
S2:SINGLE LAYER MgF2

## 4. FINE GRIND SURFACE

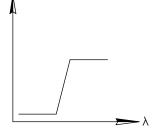
- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm (prior to coating)
- 7. ROHS COMPLIANT







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LONGPASS FILTER

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## SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

			_			<sup>©</sup> Edmund Optics <sup>®</sup>
	S1	S2				
SHAPE	PLANO	PLANO				Ø50mm, 1050nm, HIGH PERFORMANCE
SURFACE QUALITY	60-40	60-40	THIRD ANGLE . PROJECTION	$\odot$	TITLE	LONGPASS FILTER
CLEAR APERTURE	>80%	>80%		1		
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED	ALL DIMS IN	mm	DWG NO	84767 SHEET 1 OF 1